



GaAs MMIC DOUBLE-BALANCED MIXER 6-11 GHz

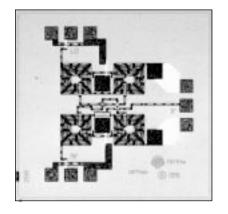
FEBRUARY 2001

Features

CONVERSION LOSS: 8 dB

LO TO RF AND IF ISOLATION: >33 dB

SMALL SIZE, NO DC BIAS REQUIRED



General Description

The HMC130 chip is a miniature double-balanced mixer which can be used as an upconverter or downconverter in the 6 to 11 band. The chip can be integrated directly into hybrid MIC's without DC bias or external baluns to provide an extremely compact mixer. It is ideally suited for Telecom and EW/ECM applications where small size, no DC Bias, and consistent IC performance is required. It performance equally as well as a Bi-Phase modulator or demodulator. See the HMC137 data sheet in section 5.

Guaranteed Performance With LO Drive of +15 dBm, -55 to +85 deg C

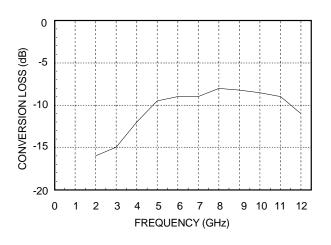
Parameter	Min.	Тур.	Max.	Units
Frequency Range, RF & LO		6.0 - 11.0		GHz
Frequency Range, IF		DC - 2		GHz
Conversion Loss		9	10	dB
Noise Figure (SSB)		9	10	dB
LO to RF Isolation	30	40		dB
LO to IF Isolation	20	30		dB
IP3 (Input)	13	18		dBm
IP2 (Input)	35	40		dBm
1 dB Gain Compression (Input)	5	10		dBm
Local Oscillator Drive Level	10	15	20	dBm



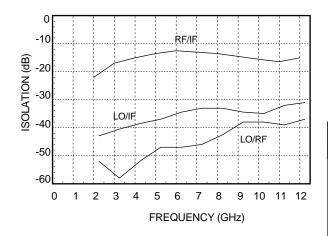
HMC130 DOUBLE-BALANCED MIXER 6 - 11 GHz

FEBRUARY 2001

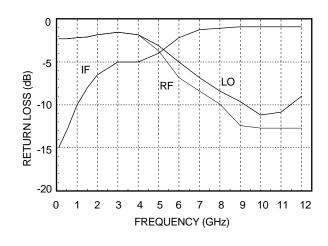
Conversion Loss



Isolation



Return Loss



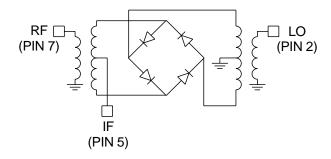
Distortion and 1dB Compression versus LO Drive Level

	Distortion		
LO Drive	RF(f1) = 8.01 GHz RF(f2) = 8.00 GHz LO = 8.5 GHz RF Level = 0 dBm		1 dBm Compression
(dBm)	IP3 (dBm)	IP2 (dBm)	(dBm)
+7	13	59	8.5
+10	16	62	10.0
+13	18	66	11.5
+15	19	68	12.0

HMC130 DOUBLE-BALANCED MIXER 6 - 11 GHz

FEBRUARY 2001

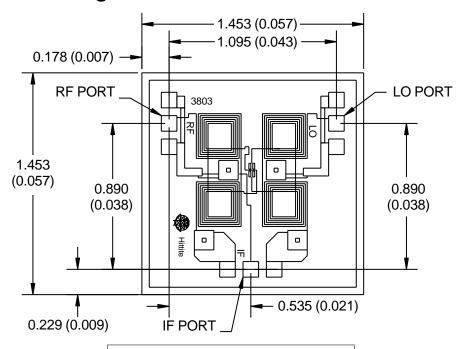
Schematic



Absolute Maximum Ratings

LO Drive	+27 dBm		
Storage Temperature	-65 to +150 deg C		
Operating Temperature	-55 to +125 deg C		

Outline Drawing



DIE THICKNESS IS 0.100 (0.004) BACKSIDE IS GROUND BOND PADS ARE 0.100 (0.004) SQUARE ALL DIMENSION IN MILLIMETERS (INCHES) ALL TOLERANCES ARE ± 0.025 (±0.001) BOND PAD METALLIZATION: GOLD BACKSIDE METALLIZATION: GOLD





HMC130 DOUBLE-BALANCED MIXER 6 - 11 GHz

FEBRUARY 2001

Handling Precautions

Follow these precautions to avoid permanent damage.

Cleanliness: Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.

Static Sensitivity: Follow ESD precautions to protect against \geq ± 250V ESD strikes (see page 8 - 2). Transients: Suppress instrument and bias supply transients while bias is applied. Use shielded signal and bias cables to minimize inductive pick-up.

General Handling: Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers. The surface of the chip has fragile air bridges and should not be touched with vacuum collet, tweezers, or fingers.

Mounting

The chip is back-metallized and can be die mounted with AuSn eutectic preforms or with electrically conductive epoxy. The mounting surface should be clean and flat.

Eutectic Die Attach:

A 80/20 gold tin preform is recommended with a work surface temperature of 255 deg. C and a tool temperature of 265 deg. C. When hot 90/10 nitrogen/hydrogen gas is applied, tool tip temperature should be 290 deg. C.

DO NOT expose the chip to a temperature greater than 320 deg. C for more than 20 seconds. No more than 3 seconds of scrubbing should be required for attachment.

Epoxy Die Attach:

Apply a minimum amount of epoxy to the mounting surface so that a thin epoxy fillet is observed around the perimeter of the chip once it is placed into position.

Cure epoxy per the manufacturer's schedule.

Wire Bonding

Ball or wedge bond with 1.0 diameter pure gold wire. Thermosonic wirebonding with a nominal stage temperature of 150 deg. C and a ball bonding force of 40 to 50 grams or wedge bonding force of 18 to 22 grams is recommended. Use the minimum level of ultrasonic energy to achieve reliable wirebonds. Wirebonds should be started on the chip and terminated on the package. RF bonds should be as short as possible.